

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application for:

Bernard Beaumont, et al.

Serial No. 10/522,397

Filed: October 21, 2005

For: METHOD FOR PRODUCING BY
VAPOUR-PHASE EPITAXY A GALLIUM
NITRIDE FILM WITH LOW DEFECT DENSITY

Examiner: Marissa W. Chaet

Art Unit: 1722

Confirmation No.: 6314

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Madam :

In response to the Office Action dated July 10, 2007 please amend the above-captioned application as set forth below.

Amendments to the Claims are reflected in the listing of claims and begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.